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**Rong et al.**

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(54) **BUNDLED MEMORY AND MANUFACTURE METHOD FOR A BUNDLED MEMORY WITH AN EXTERNAL INPUT/OUTPUT BUS**

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**H01L 27/10897** (2013.01); **H01L 2924/0002**  
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**H01L 23/544**; **H01L 21/78**; **H01L 22/32**;  
**H01L 24/03**

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USPC ..... **438/17**, **15**, **612**  
See application file for complete search history.

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(56)

**References Cited**

**U.S. PATENT DOCUMENTS**

5,691,570 A \* 11/1997 Kozuka ..... 257/693  
2002/0157082 A1 \* 10/2002 Shau ..... 716/19  
2003/0066040 A1 \* 4/2003 Morgan ..... 716/8  
2004/0113250 A1 6/2004 Khandros  
2006/0066040 A1 3/2006 Terao

\* cited by examiner

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(51) **Int. Cl.**

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**H01L 23/538** (2006.01)  
**H01L 21/768** (2006.01)  
**H01L 23/00** (2006.01)  
**H01L 21/78** (2006.01)  
**H01L 23/544** (2006.01)  
**H01L 27/108** (2006.01)

(52) **U.S. Cl.**

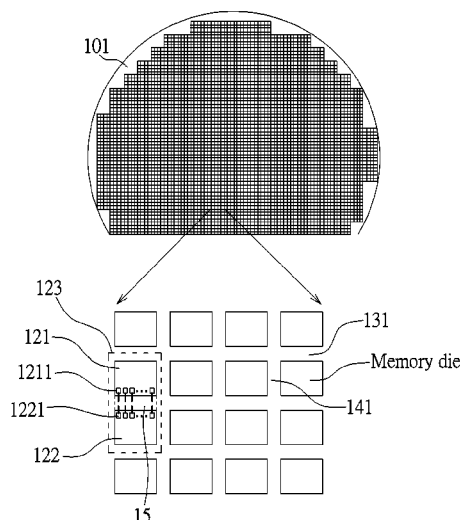
CPC ..... **H01L 25/0655** (2013.01); **H01L 21/768**  
(2013.01); **H01L 21/78** (2013.01); **H01L**  
**23/5381** (2013.01); **H01L 23/544** (2013.01);

(57)

**ABSTRACT**

A bundled memory includes a substrate, a first memory die, a second memory die, a scribe line, and an electrical connection. The first memory die has a first input/output bus, and the second memory die has a second input/output bus, where the first memory die and the second memory die are formed over the substrate. The scribe line is formed between the first memory die and the second memory die. The electrical connection is formed over the scribe line for electrically connecting to the first input/output bus and the second input/output bus, where the electrical connection is electrically connected to an external input/output bus, where a size of the external input/output bus of the bundled memory is larger than or equal to a size of the first input/output bus and a size of the second input/output bus.

**4 Claims, 5 Drawing Sheets**



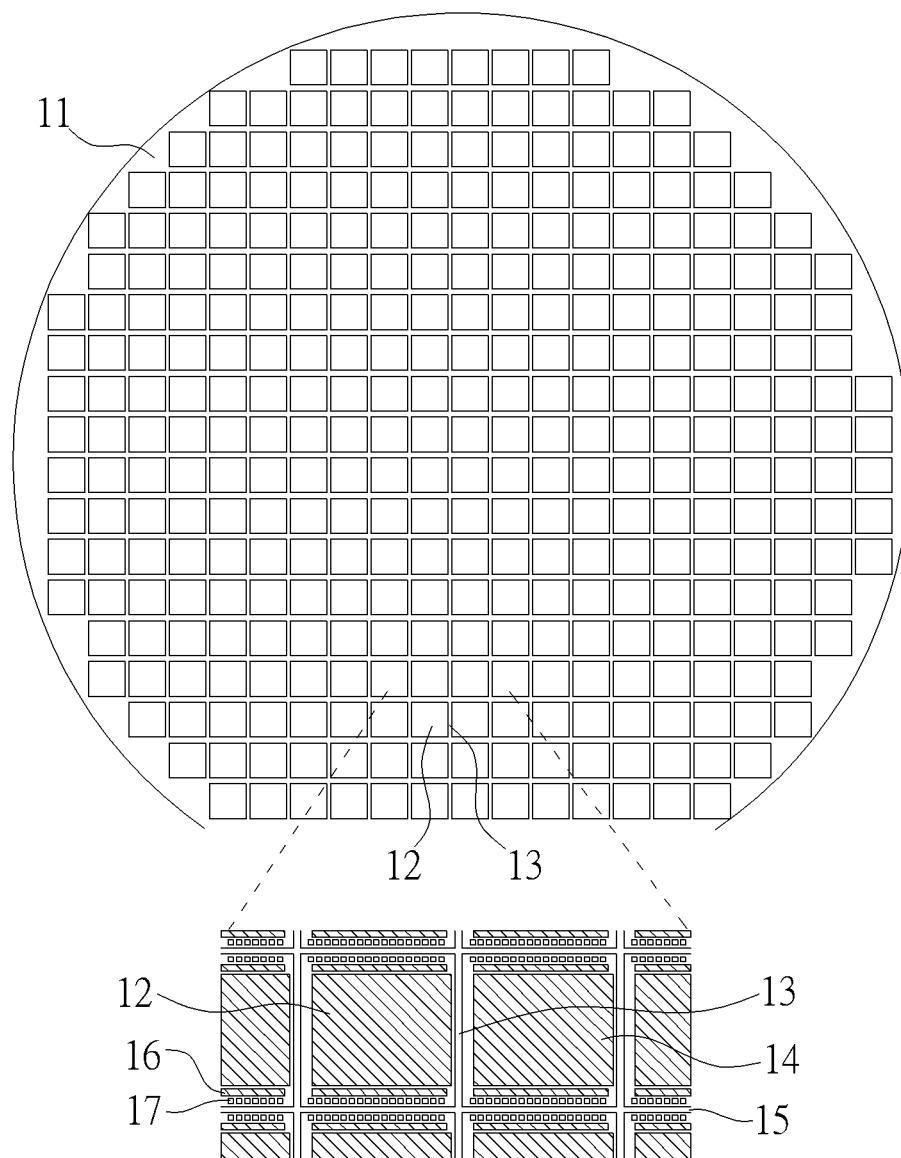


FIG. 1 PRIOR ART

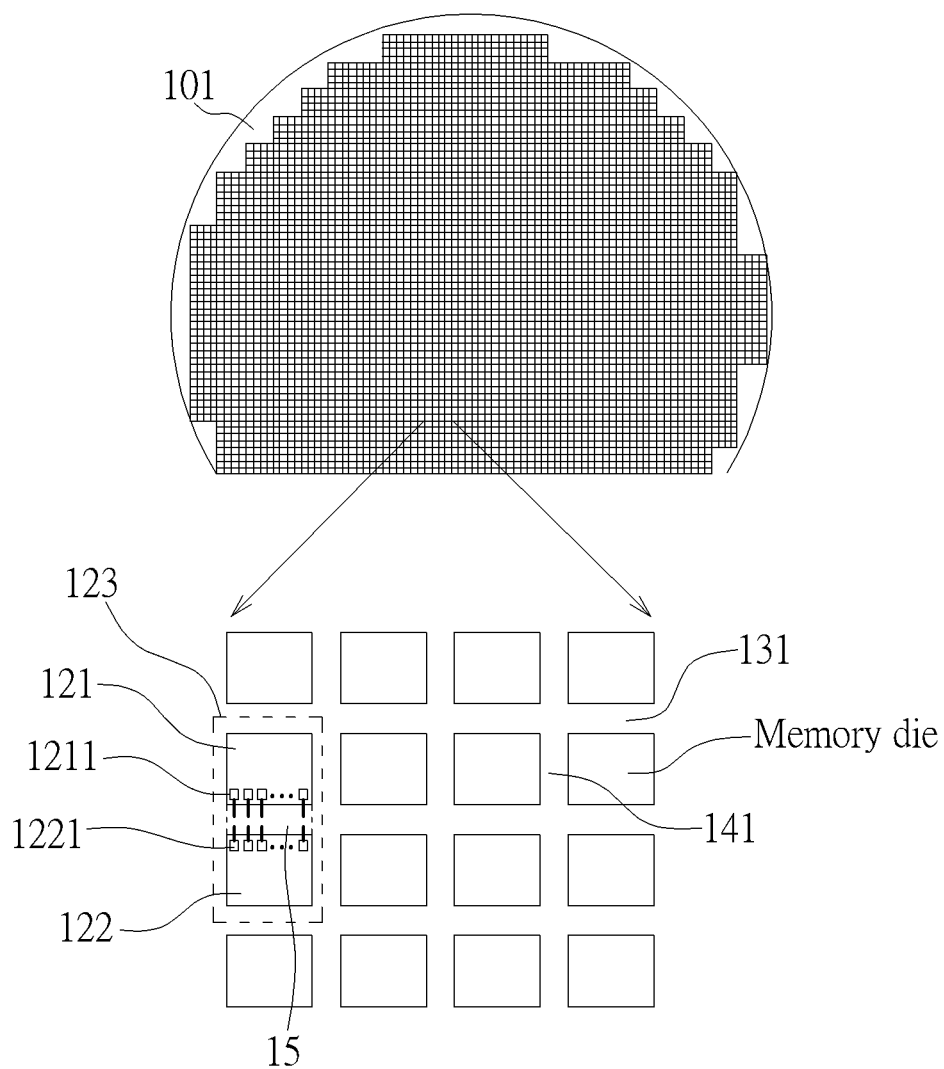


FIG. 2

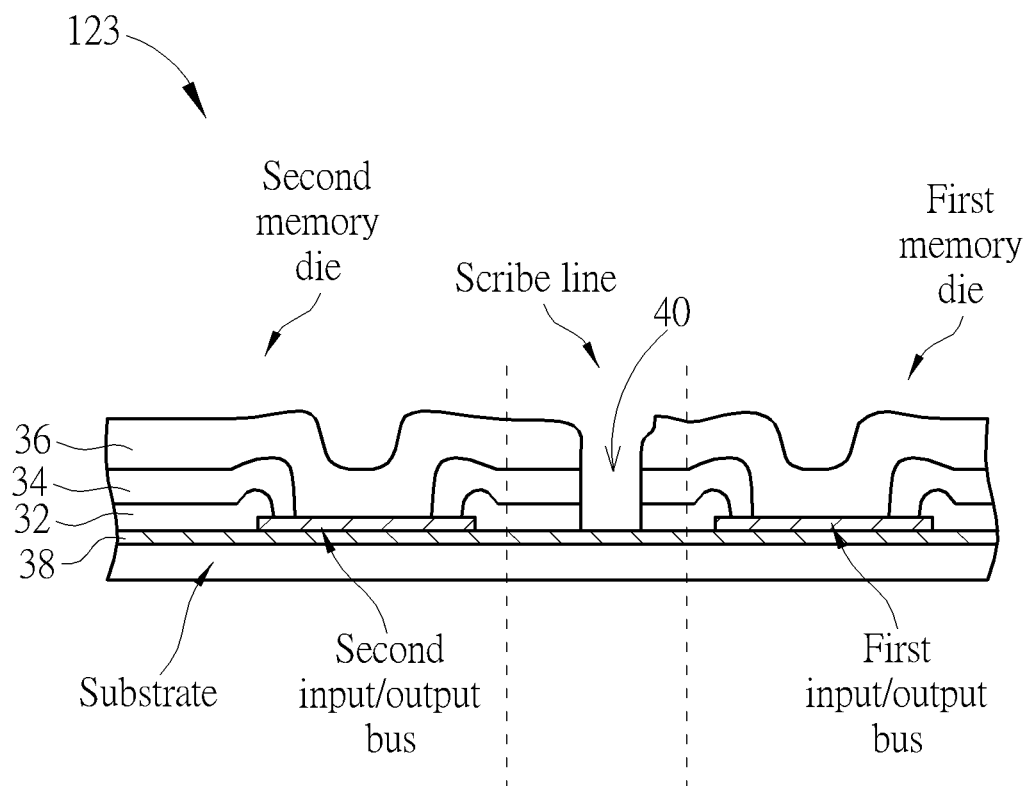


FIG. 3

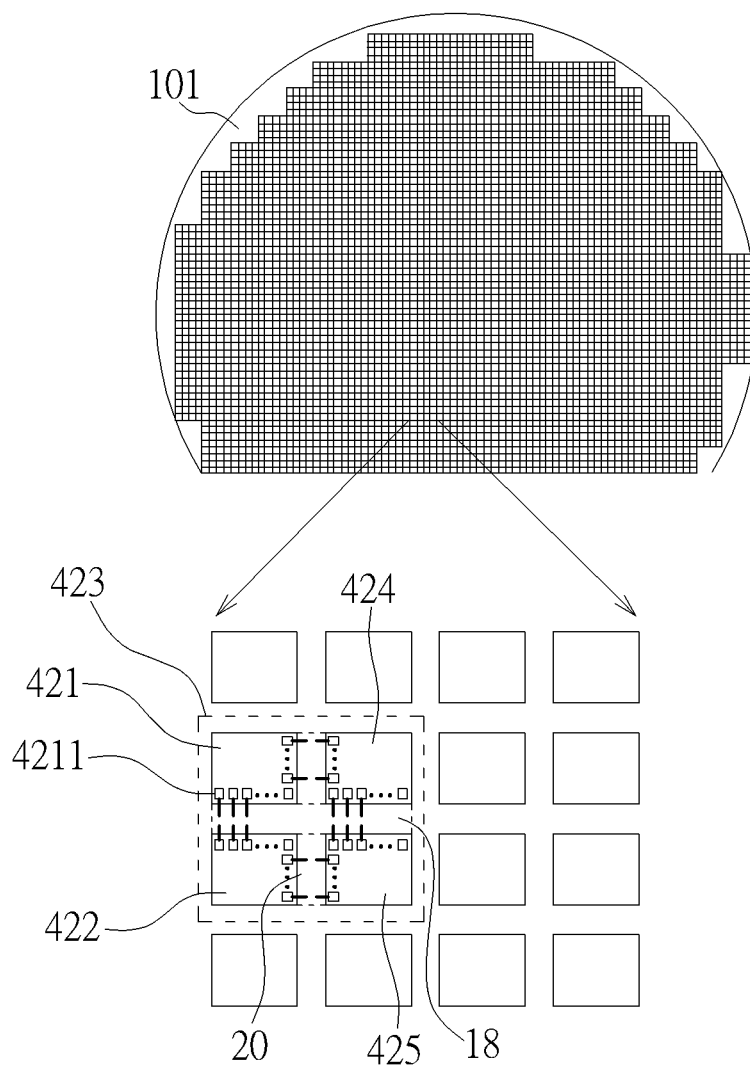


FIG. 4

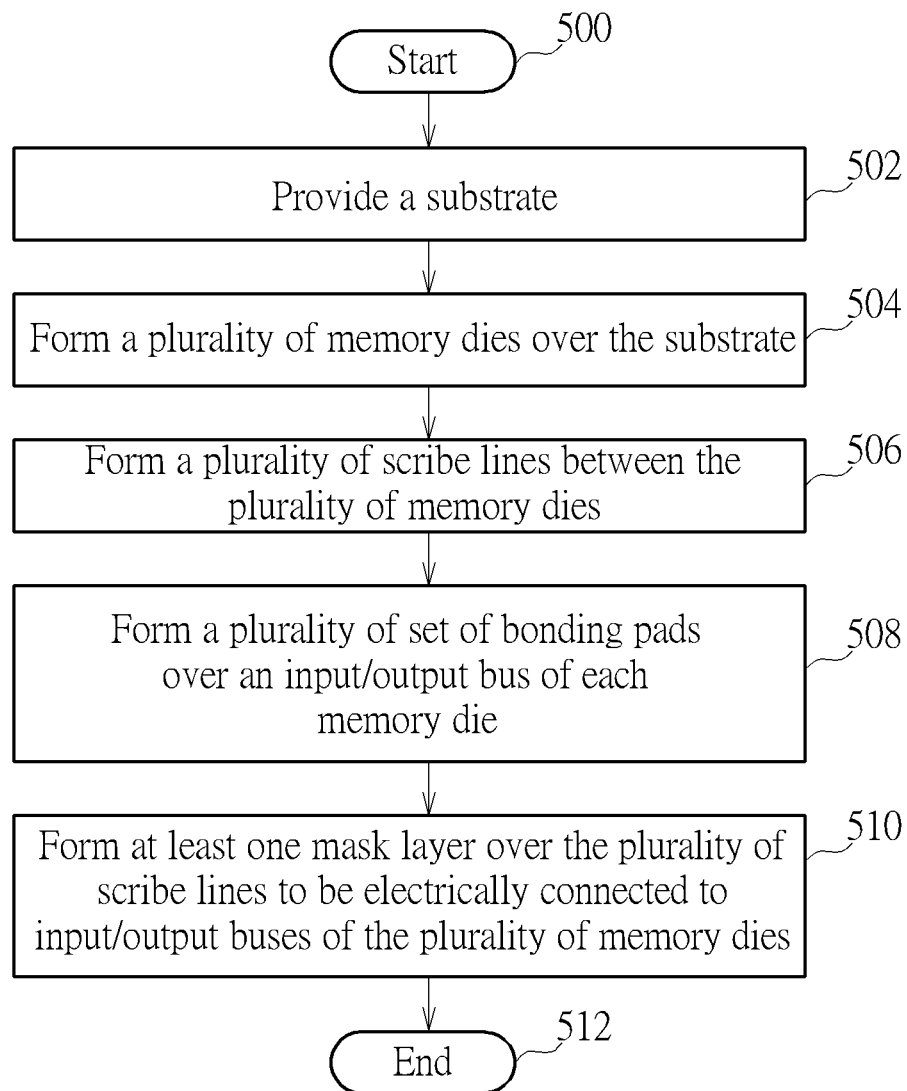


FIG. 5

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# BUNDLED MEMORY AND MANUFACTURE METHOD FOR A BUNDLED MEMORY WITH AN EXTERNAL INPUT/OUTPUT BUS

## CROSS REFERENCE TO RELATED APPLICATIONS

This is a division of U.S. patent application Ser. No. 13/798,227, filed on Mar. 13, 2013, which claims the benefit of U.S. Provisional Application No. 61/612,987 filed on Mar. 20, 2012. The above mentioned applications are included in their entirety herein by reference.

## BACKGROUND OF THE INVENTION

### 1. Field of the Invention

The present invention relates to a bundled memory and a manufacture method for a bundled memory with an external input/output bus, and particularly to a bundled memory and a manufacture method for a bundled memory with an external input/output bus that can utilize at least one mask layer formed over a plurality of scribe lines to form electrical connection coupled between input/output buses of any two memory dies.

### 2. Description of the Prior Art

Please refer to FIG. 1. FIG. 1 is a diagram illustrating a wafer 11 with a plurality of memory dies and a magnified structure of a memory die 12 according to the prior art, where the wafer 11 includes a plurality of repeating units, and each repeating unit is called a memory die (e.g. the memory die 12). As shown in FIG. 1, in the wafer 11, the memory die 12 is isolated from other dies and separated from an adjacent memory die 14 through a scribe line 13. In addition, no signal is connected over die boundaries between the memory die 12 and the memory die 14. After fabrication of the wafer 11 is completed, the wafer 11 is scribed to the plurality of memory dies (e.g. the memory die 12 and the memory die 14) into individual memory devices. As shown in FIG. 1, after the memory die 12 is cut from the wafer 11, the memory die 12 has an input/output circuit 16 and a complete set of bounding pads 17 to communicate with external circuits.

However, after fabrication of the wafer 11 is completed, memory depth and bus width of the memory die 12 and the memory die 14 are fixed. For example, the memory depth and the bus width of the memory die 12 and the memory die 14 are 2M and 32 bits, respectively. Therefore, a memory die provided by the prior art is less flexible for a user.

## SUMMARY OF THE INVENTION

An embodiment provides a bundled memory. The bundled memory includes a substrate, a first memory die, a second memory die, a scribe line, and an electrical connection. The first memory die has a first input/output bus, where the first memory die is formed over the substrate. The second memory die has a second input/output bus, where the second memory die is formed over the substrate. The scribe line is formed between the first memory die and the second memory die. The electrical connection is formed over the scribe line for electrically connecting to the first input/output bus and the second input/output bus, where the electrical connection is electrically connected to an external input/output bus, and a size of the external input/output bus is larger than or equal to a size of the first input/output bus and a size of the second input/output bus.

Another embodiment provides a manufacture method for a bundled memory with an external input/output bus. The

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manufacture method includes providing a substrate; forming a plurality of memory dies over the substrate, and forming a plurality of scribe lines between the plurality of memory dies, where each memory die has an input/output bus; forming a plurality of set of bonding pads over an input/output bus of each memory die; and forming at least one mask layer over the plurality of scribe lines to be electrically connected to the plurality of set of bonding pads of the plurality of memory dies, where the external input/output bus is electrically connected to the at least one mask layer, and the external input/output bus is larger than or equal to the input/output bus.

The present invention provides a bundled memory and a manufacture method for a bundled memory with an external input/output bus. The bundled memory and the manufacture method utilize at least one mask layer formed over a plurality of scribe lines to form electrical connection coupled between input/output buses of any two memory dies. Therefore, the bundled memory provided by the present invention is not limited to original memory depth and bus width of a memory die, that is, the bundled memory provided by the present invention can change memory depth and bus width of the bundled memory according to a requirement of a user. Thus, compared to the prior art, the bundled memory provided by the present invention is more flexible for the user.

These and other objectives of the present invention will no doubt become obvious to those of ordinary skill in the art after reading the following detailed description of the preferred embodiment that is illustrated in the various figures and drawings.

## BRIEF DESCRIPTION OF THE DRAWINGS

FIG. 1 is a diagram illustrating a wafer with a plurality of memory dies and a magnified structure of a memory die according to the prior art

FIG. 2 is a diagram illustrating a wafer with a plurality of memory dies and magnified structures of memory dies according to an embodiment.

FIG. 3 is a diagram illustrating coupling relationships between the first memory die, the second memory die, and the scribe line.

FIG. 4 is a diagram illustrating a wafer with a plurality of memory dies and a bundled memory according to another embodiment.

FIG. 5 is a flowchart illustrating a manufacture method for a bundled memory with an external input/output bus according to another embodiment.

## DETAILED DESCRIPTION

Please refer to FIG. 2. FIG. 2 is a diagram illustrating a wafer 101 with a plurality of memory dies and magnified structures of memory dies according to an embodiment. As shown in FIG. 2, the wafer 101 includes a plurality of repeating separable memory dies. The wafer 101 can be a silicon substrate, and the plurality of memory dies can be formed on the silicon substrate according to regular semiconductor process. As shown in FIG. 2, each memory die is isolated from other adjacent memory dies through a horizontal scribe line 131 and a vertical scribe line 141. However, in one embodiment of the present invention, a first memory die 121 and a second memory die 122 can be combined together to form a bundled memory 123, where the first memory die 121 and the second memory die 122 can be any memory dies. For example, the first memory die 121 and the second memory die 122 can be Single-Data-Rate (SDR) memory dies, Double-Data-Rate (DDR) memory dies, Double-Data-Rate Two

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(DDR2) memory die, Double-Data-Rate Three (DDR3) memory dies, Double-Data-Rate Four (DDR4) memory dies, or other memory dies. As shown in FIG. 2, a first input/output bus **1211** of the first memory die **121** is electrically connected to a second input/output bus **1221** of the second memory die **122**, and an electrical connection between the first memory die **121** and the second memory die **122** is formed over a scribe line **15** between the first memory die **121** and the second memory die **122**, where the electrical connection can be electrically connected to an external input/output bus of the bundled memory **123**, and an external bonding area for electrically connecting to the external input/output bus of the bundled memory **123** can be positioned over an electrical connection of the second input/output bus **1221**, the first input/output bus **1211**, or the scribe line **15**. The first input/output bus **1211** of the first memory die **121** includes a first data bus and a first address bus, the second input/output bus **1221** of the second memory die **122** includes a second data bus and a second address bus, and the external input/output bus of the bundled memory **123** includes an external data bus and an external address bus, where the external data bus can be larger than or equal to the first data bus and the second data bus, and the external address bus can be larger than or equal to the first address bus and the second address bus. For example, if memory depth of the first memory die **121** and the second memory die **122** is 2M and bus width of the first memory die **121** and the second memory die **122** is 32 bits, and the first data bus of the first input/output bus **1211** is electrically connected to the second data bus of the second input/output bus **1221**, memory depth of the bundled memory **123** is 4M and bus width of the bundled memory **123** is 32 bits. However, if the first address bus of the first input/output bus **1211** is electrically connected to the second address bus of the second input/output bus **1221**, the memory depth of the bundled memory **123** is 2M and the bus width of the bundled memory **123** is 64 bits.

In another embodiment of the present invention, the memory depth and the bus width of the first memory die **121** can be different from the memory depth and the bus width of the second memory die **122**. For example, the memory depth and the bus width of the first memory die **121** are 2M and 32 bits, respectively, and the memory depth and the bus width of the second memory die **122** are 4M and 32 bits, respectively. Therefore, after the first data bus of the first memory die **121** is electrically connected to the second data bus of the second memory die **122** to form a bundled memory, memory depth and bus width of the bundled memory are 6M and 32 bits, respectively. On the other hand, if the memory depth and the bus width of the first memory die **121** are 2M and 32 bits, respectively, and the memory depth and the bus width of the second memory die **122** are 2M and 64 bits, respectively, after the first address bus of the first memory die **121** is electrically connected to the second address bus of the second memory die **122** to form a bundled memory, memory depth and bus width of the bundled memory are 2M and 96 bits, respectively.

In addition, the electrical connection formed over the scribe line **15** can be wire bonding connection, redistribution layer (RDL), or another connection implemented by available semiconductor processes. For example, the wafer **101** having the plurality of repeating separable memory dies is first provided, where the wafer **101** is made through a plurality of masks. Then, bonding pads of the first input/output bus **1211** and bonding pads of the second input/output bus **1221** are formed over the first memory die **121** and the second memory die **122**, respectively. In addition, at least one mask is formed over the scribe line **15**. Thus, the bonding pads of the first

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input/output bus **1211** and the bonding pads of the second input/output bus **1221** can be electrically connected through the at least one mask formed over the scribe line **15**. The at least one mask formed over the scribe line **15** can be corresponding to a metal layer, a polysilicon layer, or another semiconductor layer.

In another embodiment of the present invention, at least one mask layer made by semiconductor process can be deposited over the scribe line **15**. Thus, the bonding pads of the first input/output bus **1211** and the bonding pads of the second input/output bus **1221** can be electrically connected each other, and the external bonding area of the bundled memory **123** can be redistributed or located over the scribe line **15**. Please refer to FIG. 3. FIG. 3 is a diagram illustrating coupling relationships between the first memory die **121**, the second memory die **122**, and the scribe line **15**. As shown in FIG. 3, a passivation material layer **32**, a first polyimide layer **34**, a second polyimide layer **36** and a metal layer (or a polysilicon layer) **38** are deposited over the scribe line **15**. The bonding pads of the second input/output bus **1221** is deposited over the second memory die **122**, and the bonding pads of the first input/output bus **1211** deposited over the first memory die **121**. In addition, the metal layer **38** is electrically connected to the bonding pads of the second input/output bus **1221** and the bonding pads of the first input/output bus **1211**. As shown in FIG. 3, the bundled memory **123** has a relocated external bonding point **40**, so an external bonding pad can be formed at the external bonding point **40** to be electrically connected to the bonding pads of the second input/output bus **1221** and the bonding pads of the first input/output bus **1211**. But, the external bonding point **40** of the present invention is not limited to be located over the scribe line **15**. In another embodiment of the present invention, the external bonding point **40** can also be located over the bonding pads of the second input/output bus **1221** or the bonding pads of the first input/output bus **1211**. Moreover, a plurality of testing pads (not shown in FIG. 3) can be deposited over the second polyimide layer **36** and located within the scribe line **15** to test the bundled memory **123**, where the plurality of testing pads are electrically connected to the external input/output bus of the bundled memory **123**. In addition, a plurality of testing circuits can also be deposited over the scribe line **15** included in the bundled memory **123**.

Please refer to FIG. 4. FIG. 4 is a diagram illustrating a wafer **101** with a plurality of memory dies and a bundled memory **423** according to another embodiment. As shown in FIG. 4, four separable memory dies **421**, **422**, **424**, and **425** can be combined together to form the bundled memory **423**, where an input/output bus **4211** of the memory die **421** is electrically connected to input/output buses of the memory dies **422**, **424**, and **425**. Electrical connections between the four memory dies **421**, **422**, **424**, and **425** are formed over a horizontal scribe line **18** and/or a vertical scribe line **20** between the four memory dies **421**, **422**, **424**, and **425**. If memory depth of each memory die of the four memory dies **421**, **422**, **424**, and **425** is 2M and bus width of each memory die of the four memory dies **421**, **422**, **424**, and **425** is 32 bits, and data buses of input/output buses of the four memory dies **421**, **422**, **424**, and **425** are electrically connected together, memory depth and bus width of the bundled memory **423** are 8M and 32 bits, respectively; if address buses of the input/output buses of the four memory dies **421**, **422**, **424**, and **425** are electrically connected together, the memory depth and the bus width of bundled memory **423** are 2M and 128 bits, respectively. In addition, an external bonding area for electrically connecting to an external input/output bus of the bundled memory **423** can be located over the input/output



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buses of the four memory dies **421**, **422**, **424**, and **425**, the horizontal scribe line **18**, or the vertical scribe line **20**.

In addition, the bundled memories of the present invention are not limited to being composed of two separable memory dies and four separable memory dies. That is to say, the bundled memories of the present invention can be composed of a plurality of separable memory dies.

Please refer to FIG. 2 and FIG. 5. FIG. 5 is a flowchart illustrating a manufacture method for a bundled memory with an external input/output bus according to another embodiment. The manufacture method in FIG. 5 is illustrated using the wafer **101**, the horizontal scribe line **131**, the vertical scribe line **141**, and the bundled memory **123** in FIG. 2. Detailed steps are as follows:

Step **500**: Start.

Step **502**: Provide a substrate.

Step **504**: Form a plurality of memory dies over the substrate.

Step **506**: Form a plurality of scribe lines between the plurality of memory dies.

Step **508**: Form a plurality of set of bonding pads over an input/output bus of each memory die.

Step **510**: Form at least one mask layer over the plurality of scribe lines to be electrically connected to input/output buses of the plurality of memory dies.

Step **512**: End.

In Step **502**, as shown in FIG. 2, provide the substrate (e.g. the wafer **101**), where the wafer **101** can be a silicon substrate. In Step **504** and Step **506**, the plurality of memory dies can be formed on the silicon substrate (the wafer **101**) according to the regular semiconductor process, and the plurality of scribe lines can be formed between the plurality of memory dies, e.g. the horizontal scribe line **131** and the vertical scribe line **141** shown in FIG. 2. In Step **508**, form a plurality of set of bonding pads over an input/output bus of each memory die. For example, as shown in FIG. 2, the bonding pads of the first input/output bus **1211** and the bonding pads of the second input/output bus **1221** are formed over the first memory die **121** and the second memory die **122**, respectively. In Step **510**, form at least one mask layer over the plurality of scribe lines. For example, form at least one mask over the scribe line **15**. Thus, the bonding pads of the first input/output bus **1211** and the bonding pads of the second input/output bus **1221** can be electrically connected through the at least one mask formed over the scribe line **15**, where the at least one mask formed over the scribe line **15** can be corresponding to a metal layer, a polysilicon layer, or another semiconductor layer.

As shown in FIG. 2, the first memory die **121** and the second memory die **122** can be electrically connected together to form the bundled memory **123** through the manufacture method in FIG. 5. Therefore, the first input/output bus **1211** of the first memory die **121** is electrically connected to the second input/output bus **1221** of the second memory die **122**, and the electrical connections between the first memory die **121** and the second memory die **122** are formed over the scribe line **15** between the first memory die **121** and the second memory die **122**. If the first data bus of the first input/output bus **1211** is electrically connected to the second data bus of the second input/output bus **1221**, the memory depth of the bundled memory **123** is greater than the memory depth of the first memory die **121** and the second memory die **122**. However, if the first address bus of the first input/output bus **1211** is electrically connected to the second address bus of the second input/output bus **1221**, the bus width of the bundled memory **123** is greater than the bus width of the first memory die **121** and the second memory die **122**. In addition, the external bonding area for electrically connecting to the

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input/output bus of the bundled memory **123** can be positioned over the second input/output bus **1221**, the first input/output bus **1211**, or the scribe line **15**.

In another embodiment of the present invention, at least one mask layer made by semiconductor process can be deposited over the scribe line **15**. Thus, the bonding pads of the first input/output bus **1211** and the bonding pads of the second input/output bus **1221** can be electrically connected each other, and the external bonding area of the bundled memory **123** can be redistributed or located over the first input/output bus **1211**, the second input/output bus **1221**, or the scribe line **15**. For example, as shown in FIG. 3, the bundled memory **123** has the relocated external bonding point **40** (other external bonding points of the bundled memory **123** not shown in FIG. 3), so an external bonding pad can be formed at the external bonding point **40** to be electrically connected to the bonding pads of the second input/output bus **1221** and the bonding pads of the first input/output bus **1211**, where the external bonding point **40** is distributed over the scribe line **15**. Moreover, a plurality of testing pads (not shown in FIG. 3) can be deposited over the second polyimide layer **36** and located within the scribe line **15** to test the bundled memory **123**, where the plurality of testing pads are electrically connected to the external input/output bus of the bundled memory **123**. In addition, a plurality of testing circuits can also be deposited over the scribe line **15** included in the bundled memory **123**.

To sum up, the bundled memory and the manufacture method for a bundled memory with an external input/output bus utilize at least one mask layer formed over the plurality of scribe lines to form electrical connection coupled between input/output buses of any two memory dies. Therefore, the bundled memory provided by the present invention is not limited to original memory depth and bus width of a memory die, that is, the bundled memory provided by the present invention can change the memory depth and the bus width of the bundled memory according to a requirement of a user. Thus, compared to the prior art, the bundled memory provided by the present invention is more flexible for the user.

Those skilled in the art will readily observe that numerous modifications and alterations of the device and method may be made while retaining the teachings of the invention. Accordingly, the above disclosure should be construed as limited only by the metes and bounds of the appended claims.

What is claimed is:

1. A manufacture method for a bundled memory with an external input/output bus, the manufacture method comprising:

- providing a substrate;
- forming a plurality of memory dies over the substrate, and forming a plurality of scribe lines between the plurality of memory dies;
- forming a plurality of masked layers over the plurality of scribe lines, wherein the plurality of masked layers form an electrical connection, and the external input/output bus is electrically connected to the electrical connection; and
- forming a plurality of test pads over the plurality of masked layers, wherein the plurality of test pads are positioned over the scribe line;
- wherein a plurality of external bonding pads are electrically connected to the plurality of test pads.

2. The manufacture method of claim 1, wherein the plurality of external bonding pads are distributed over the plurality of scribe lines or the input/output buses of the plurality of memory dies.

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3. A manufacture method for a bundled memory with an external input/output bus, the manufacture method comprising:

providing a substrate;

forming a plurality of memory dies over the substrate, and  
forming a plurality of scribe lines between the plurality  
of memory dies, wherein each memory die has an input/  
output bus;

forming a plurality of masked layers over the plurality of  
scribe lines to form an electrical connection for electri-  
cally connecting to an input/output bus of each memory  
die of the bundled memory, wherein the external input/  
output bus is electrically connected to the electrical con-  
nection;

wherein a memory depth of the bundled memory is larger  
than a memory depth of the each memory die of the  
bundled memory.

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4. A manufacture method for a bundled memory with an external input/output bus, the manufacture method comprising:

providing a substrate;

forming a plurality of memory dies over the substrate, and  
forming a plurality of scribe lines between the plurality  
of memory dies, wherein each memory die has an input/  
output bus;

forming a plurality of masked layers over the plurality of  
scribe lines to form an electrical connection for electri-  
cally connecting to an input/output bus of each memory  
die of the bundled memory, wherein the external input/  
output bus is electrically connected to the electrical con-  
nection;

wherein a memory depth and a bus width of at least one  
memory die of the bundled memory are different from  
memory depths and bus widths of other memory dies of  
the bundled memory.

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